



Docket No: TSMC2003-0017/24061.506  
Customer Number: 42717

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:  
Lin et al.

Serial No.: 10/718,876

Filed: 11/21/2003

For: Phosphoric Acid Free Process for  
Polysilicon Gate Definition

§ Attorney Docket: TSMC2003-0017/24061.506  
§  
§ Confirmation Number: 1467  
§  
§ Art Unit: 2813  
§  
§ Examiner: Nguyen, Thanh T.  
§  
§ Notice of Allowance: 09/20/2004

Commissioner for Patents  
PO Box 1450  
Alexandria, VA 22313-1450  
MAIL STOP ISSUE FEE

TRANSMITTAL

Dear Sir:

In response to the Notice of Allowance and Issue Fee Due mailed on September 20, 2004, enclosed are the following:

1. Part B - Issue Fee Transmittal (in duplicate);
2. Check in the amount of \$1670.00;
3. Revocation and New Power of Attorney (2 pages);
4. Fee Address Indication Form; and
5. Return postcard.

The Commissioner is hereby authorized to charge Deposit Account No. 08-1394 for any deficiencies in the enclosed fees. This sheet submitted in duplicate.

Respectfully submitted,

David M. O'Dell  
Registration No. 42,044

Date: 11-29-04  
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R92166.1

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner for Patents  
PO Box 1450, Alexandria, VA 22313-1450

on

11-30-04  
  
Bonnie E. Boyle